

| L Number | Hits | Search Text | DB | Time stamp |
|----------|------|--|---|------------------|
| 1 | 27 | ((313/582-587).CCLS.) and (lead adj oxide pbo) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") and powder same (coat\$5 layer\$5 jacket\$5 film skin plating plated sublayer sub adj layer lamina\$5) same (firing fired) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/13 10:44 |
| 2 | 27 | ((313/582-587).CCLS.) and (lead adj oxide pbo) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") and powder same (coat\$5 layer\$5 jacket\$5 film skin plating plated sublayer sub adj layer lamina\$5) same (firing fired) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/13 10:50 |
| 3 | 11 | ((313/582-587).CCLS.) and (lead adj oxide pbo) and powder same (coat\$5 layer\$5 jacket\$5 film skin plating plated sublayer sub adj layer lamina\$5) same (firing fired) same dielectric adj (coat\$5 layer\$5 jacket\$5 film skin plating plated sublayer sub adj layer lamina\$5) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/13 12:15 |
| 4 | 2 | 6160345.pn. | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/13 11:32 |
| 5 | 2 | 6160345.pn. and dielectric adj layer | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/13 11:33 |
| 6 | 1 | 6160345.pn. and dielectric adj layer same powder | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/13 11:34 |
| 7 | 1 | 6160345.pn. and dielectric adj layer and powder | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/13 11:36 |
| 8 | 2 | 6160345.pn. and dielectric adj layer same (bake baking baked) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/13 11:36 |
| 9 | 0 | 6160345.pn. and dielectric adj layer same (bake baking baked) same powder | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/13 11:37 |
| 10 | 1 | 6160345.pn. and dielectric adj layer same (bake baking baked) and powder\$5 | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/13 11:37 |
| 11 | 2 | 20040027071.did. | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/13 11:52 |
| 12 | 2 | 20040027071.did. and pigment | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/13 11:58 |
| 13 | 61 | calcium adj oxide near2 pigment | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/13 12:00 |

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|----|-----|--|---|------------------|
| 14 | 0 | ((315/169.3).CCLS. (345/60).ccls.) and (lead adj oxide pbo) and powder same (coat\$5 layer\$5 jacket\$5 film skin plating plated sublayer sub adj layer lamina\$5) same (firing fired) same dielectric adj (coat\$5 layer\$5 jacket\$5 film skin plating plated sublayer sub adj layer lamina\$5) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/13 12:16 |
| 15 | 10 | ((315/169.3).CCLS. (345/60).ccls.)) and (lead adj oxide pbo) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") and ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")) and (percent\$6 "%") | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/13 12:16 |
| 16 | 10 | ((315/169.3).CCLS. (345/60).ccls.)) and (lead adj oxide pbo) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") and ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")) and (percent\$6 "%") | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/13 12:32 |
| 17 | 2 | 20010024582.did. | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/13 12:32 |
| 18 | 2 | 6160345.pn. | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/13 12:33 |
| 19 | 1 | 6160345.pn. and soften\$6 | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/13 12:33 |
| - | 10 | ("6617789" "6497962" "6419540" "6160345" "6376400" "6355586" "5948537" "5714840").pn. ("20020034917" "20020036466").did. | USPAT; US-PGPUB | 2004/10/12 16:22 |
| - | 209 | glass.ab,ti,clm. and (lead adj oxide PbO) and (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") and (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") and (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") and (zirconium adj oxide "ZrO.sub.2") and (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") and (tantalum adj oxide "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5") | USPAT; US-PGPUB | 2004/10/12 13:38 |
| - | 212 | glass.ab,ti,clm. and (lead adj oxide PbO) and (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") and (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") and (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") and (zirconium adj oxide "ZrO.sub.2") and (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") and (tantalum adj oxide "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5") | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 13:38 |

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|---|-----|---|---|------------------|
| - | 147 | glass.ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") and (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") and (zirconium adj oxide "ZrO.sub.2") and (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") and (tantalum adj oxide "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5") | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 13:39 |
| - | 77 | glass.ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") same (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") same (zirconium adj oxide "ZrO.sub.2") same (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") same (tantalum adj oxide "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5") | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 13:39 |
| - | 72 | glass.ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") same (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") same (zirconium adj oxide "ZrO.sub.2") same (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") same (tantalum adj oxide "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5") and (percent "%") | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 13:40 |
| - | 72 | glass.ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") same (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") same (zirconium adj oxide "ZrO.sub.2") same (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") same (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5") and (percent "%") | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 13:40 |
| - | 40 | glass.ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") same (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") same (zirconium adj oxide "ZrO.sub.2") same (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") same (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5") same (percent "%") | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 13:43 |
| - | 9 | glass.ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") same (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") same (zirconium adj oxide "ZrO.sub.2") same (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") same (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5") same (percent "%") and softening adj point | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 13:44 |

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|---|-----|---|---|------------------|
| - | 6 | glass.ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") same (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") same (zirconium adj oxide "ZrO.sub.2") same (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") same (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5") same (percent "%") and plasma | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 14:50 |
| - | 1 | "20040180773" | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 13:57 |
| - | 1 | 20040180773.did. | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 13:57 |
| - | 0 | ((("6617789" "6497962" "6419540" "6160345" "6376400" "6355586" "5948537" "5714840").pn. ("20020034917" "20020036466").did.) and (lead adj oxide PbO) and (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") and (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") and (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") and (zirconium adj oxide "ZrO.sub.2") and (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") and (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5") and (percent "%") | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 14:17 |
| - | 0 | ((("6617789" "6497962" "6419540" "6160345" "6376400" "6355586" "5948537" "5714840").pn. ("20020034917" "20020036466").did.) and (lead adj oxide PbO) and (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") and (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") and (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") and (zirconium adj oxide "ZrO.sub.2") and (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") and (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5") | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 14:22 |
| - | 228 | (fujimine near2 satoshi manabe near2 tsuneo).in. | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 14:18 |
| - | 28 | ((fujimine near2 satoshi manabe near2 tsuneo).in.) and glass near2 powder and (lead adj oxide pbo) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 14:40 |
| - | 1 | ((fujimine near2 satoshi manabe near2 tsuneo).in.) and glass near2 powder and (lead adj oxide pbo) and (lead adj oxide PbO) and (boron adj (trioxide oxide) "B.sub.20.sub.3" "B.sub.2 O.sub.3") and (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") and (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") and (zirconium adj oxide "ZrO.sub.2") and (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") and (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5") | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 14:38 |

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|---|----|--|---|------------------|
| - | 1 | 20040027071.did. and "TiO.sub.2" | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 14:38 |
| - | 8 | ((fujimine near2 satoshi manabe near2 tsuneo).in.) and glass near2 powder and (lead adj oxide pbo)) and "+" | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 14:41 |
| - | 3 | ((fujimine near2 satoshi manabe near2 tsuneo).in.) and glass near2 powder and (lead adj oxide pbo)) and "+.clm. | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 14:41 |
| - | 57 | glass.ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")) same (percent "%") and plasma | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 14:51 |
| - | 57 | glass.ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")) same (percent "%") and plasma | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 14:52 |
| - | 8 | glass.ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")) same (percent "%") and plasma and (copper adj oxide CuO) and (sapphire sapphire aluminum adj oxide "al.sub.20.sub.3" "al.sub.2 O.sub.3") and (barium adj oxide bao) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 15:06 |
| - | 2 | 6555594.URPN. | USPAT | 2004/10/12 15:05 |
| - | 9 | (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica).ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica) same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")) same (percent "%") and plasma and (copper adj oxide CuO) and (sapphire sapphire aluminum adj oxide "al.sub.20.sub.3" "al.sub.2 O.sub.3") and (barium adj oxide bao) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 15:07 |

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|---|-----|--|---|------------------|
| - | 52 | (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica).ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica) same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")) same (percent "%") and plasma and ((copper adj oxide CuO) (sapphire sapphire aluminum adj oxide "al.sub.20.sub.3" "al.sub.2 O.sub.3") and (barium adj oxide baO))) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 15:10 |
| - | 15 | (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica).ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica) same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")) same (percent "%") same ((copper adj oxide CuO) (sapphire sapphire aluminum adj oxide "al.sub.20.sub.3" "al.sub.2 O.sub.3") and (barium adj oxide baO))) and plasma | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 15:36 |
| - | 199 | (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica).ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica) same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")) same (percent "%") same ((copper adj oxide CuO) (sapphire sapphire aluminum adj oxide "al.sub.20.sub.3" "al.sub.2 O.sub.3") and (barium adj oxide baO))) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 15:37 |
| - | 4 | (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica).ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica) same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")) same (percent "%") same ((copper adj oxide CuO) (sapphire sapphire aluminum adj oxide "al.sub.20.sub.3" "al.sub.2 O.sub.3") and (barium adj oxide baO))) and pdp | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 15:40 |

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|---|-----|--|---|------------------|
| - | 8 | (plasma adj display adj panel pdp).ab.ti.clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica) same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")) same (percent "%") same ((copper adj oxide CuO) (sapphire sapphire aluminum adj oxide "al.sub.20.sub.3" "al.sub.2 O.sub.3") and (barium adj oxide bao))) and softening adj point | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 15:53 |
| - | 2 | 20020096666.did. | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 16:38 |
| - | 1 | 6238847.pn. and barium | USPAT; US-PGPUB | 2004/10/12 16:23 |
| - | 1 | 6238847.pn. and (barium BaO) | USPAT; US-PGPUB | 2004/10/12 16:27 |
| - | 0 | 6238847.pn. and softening | USPAT; US-PGPUB | 2004/10/12 16:27 |
| - | 1 | 6238847.pn. | USPAT; US-PGPUB | 2004/10/12 16:36 |
| - | 1 | 20020096666.did. and electrode | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 16:42 |
| - | 487 | (313/586).CCLS. | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 16:42 |
| - | 113 | ((313/586).CCLS.) and (lead adj oxide pbo) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 16:42 |
| - | 53 | ((313/586).CCLS.) and (lead adj oxide pbo) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 16:43 |
| - | 18 | ((313/586).CCLS.) and (lead adj oxide pbo) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") and ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 16:45 |
| - | 5 | ((313/586).CCLS.) and (lead adj oxide pbo) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 16:44 |

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|---|----|---|---|------------------|
| - | 15 | ((313/586).CCLS.) and (lead adj oxide pbo) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") and ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")) and (percent%6 "%") | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 22:30 |
| - | 2 | 20010024582.did. | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 16:59 |
| - | 1 | 20010024582.did. and softening adj point | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/12 16:59 |
| - | 1 | 20010024582.did. | USPAT; US-PGPUB | 2004/10/12 22:03 |
| - | 1 | 20010024582.did. and BaO | USPAT; US-PGPUB | 2004/10/12 22:05 |
| - | 1 | 20010024582.did. and BaO same PbO | USPAT; US-PGPUB | 2004/10/12 22:16 |
| - | 1 | 20010024582.did. and softening adj point | USPAT; US-PGPUB | 2004/10/12 22:16 |
| - | 2 | 20040027071.did. | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/13 11:52 |
| - | 38 | ((313/582-587).CCLS.) and (lead adj oxide pbo) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") and ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")) and (percent%6 "%") | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/13 12:16 |
| - | 1 | 6160345.pn. | USPAT; US-PGPUB | 2004/10/12 22:46 |